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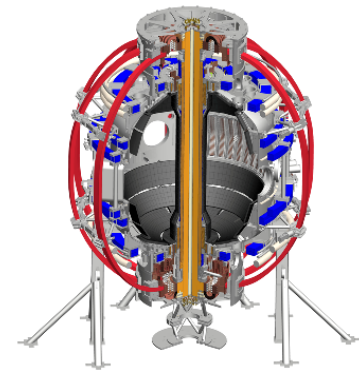
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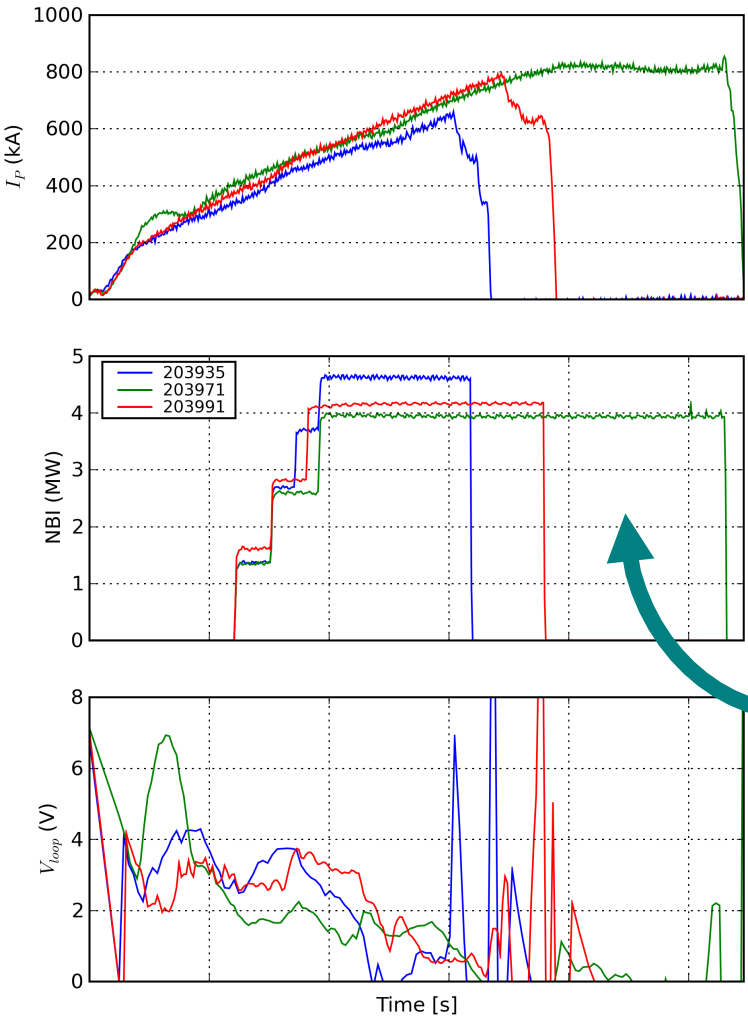
# Characterization of boronized graphite in NSTX-U and its effect on plasma performance

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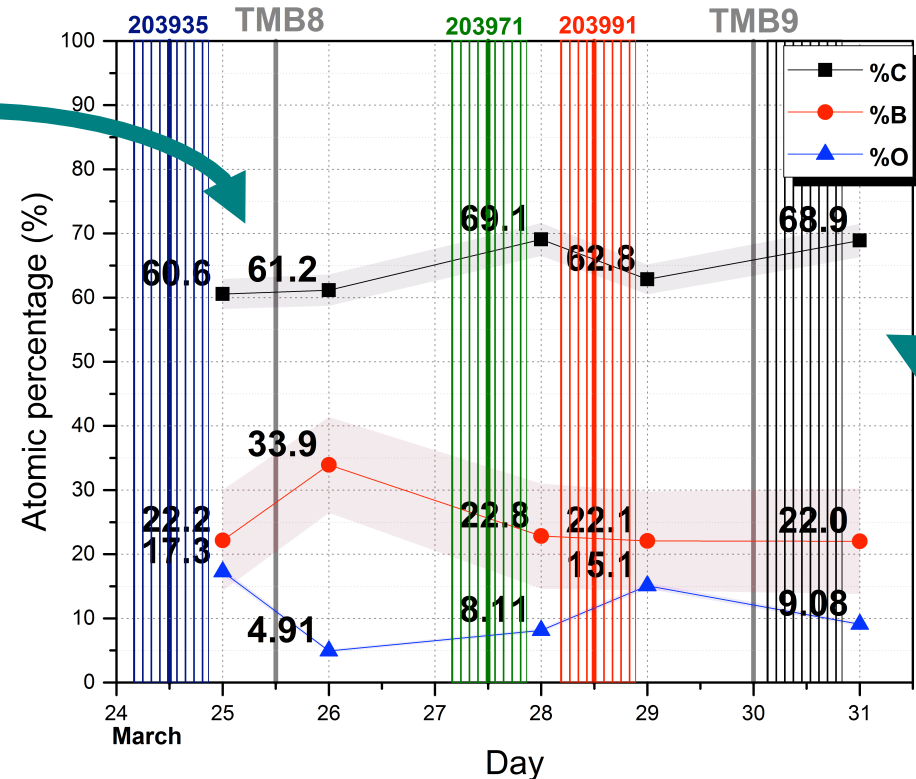


# Motivation



Low oxygen concentration following boronization

Improved plasma performance on similar scenarios



MAPP XPS data obtained at NSTX-U

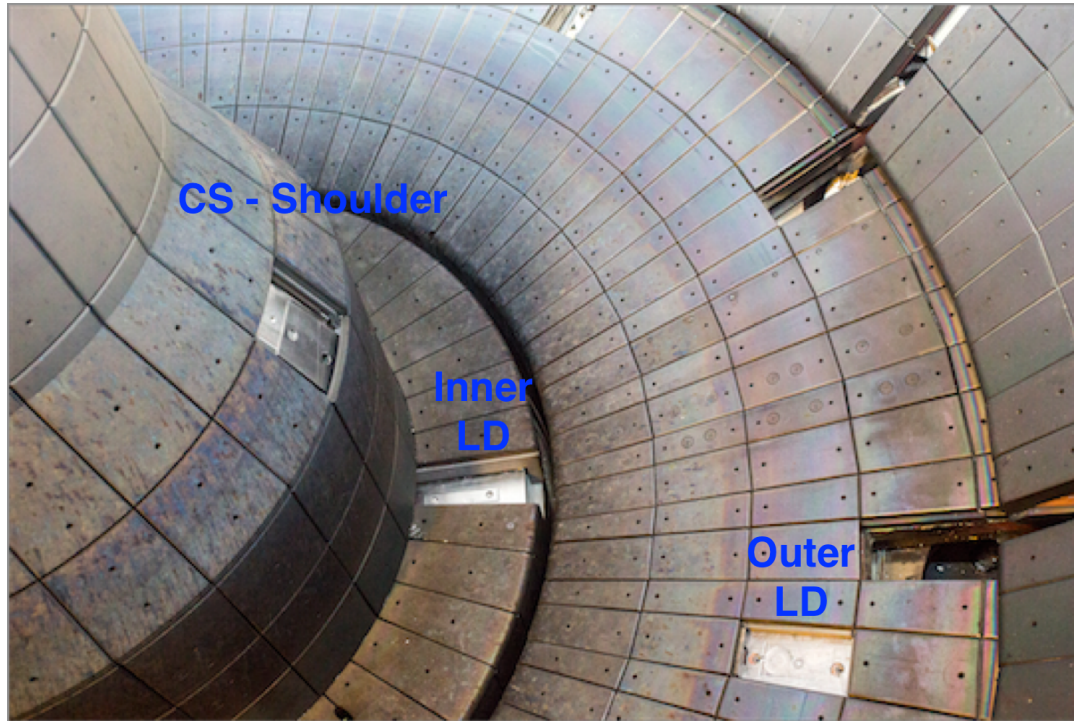
Oxygen concentration reduction in PFCs with boronization seems to help improving performance.

Further studies in the laboratory (*post-mortem and control*) to test this hypothesis



# Experimental methods

## Core samples



## Tiles location

- A18, Center Stack (CS) Shoulder
- B17, Inner Lower Divertor (ILD)
- C18, Outer Lower Divertor (OLD)

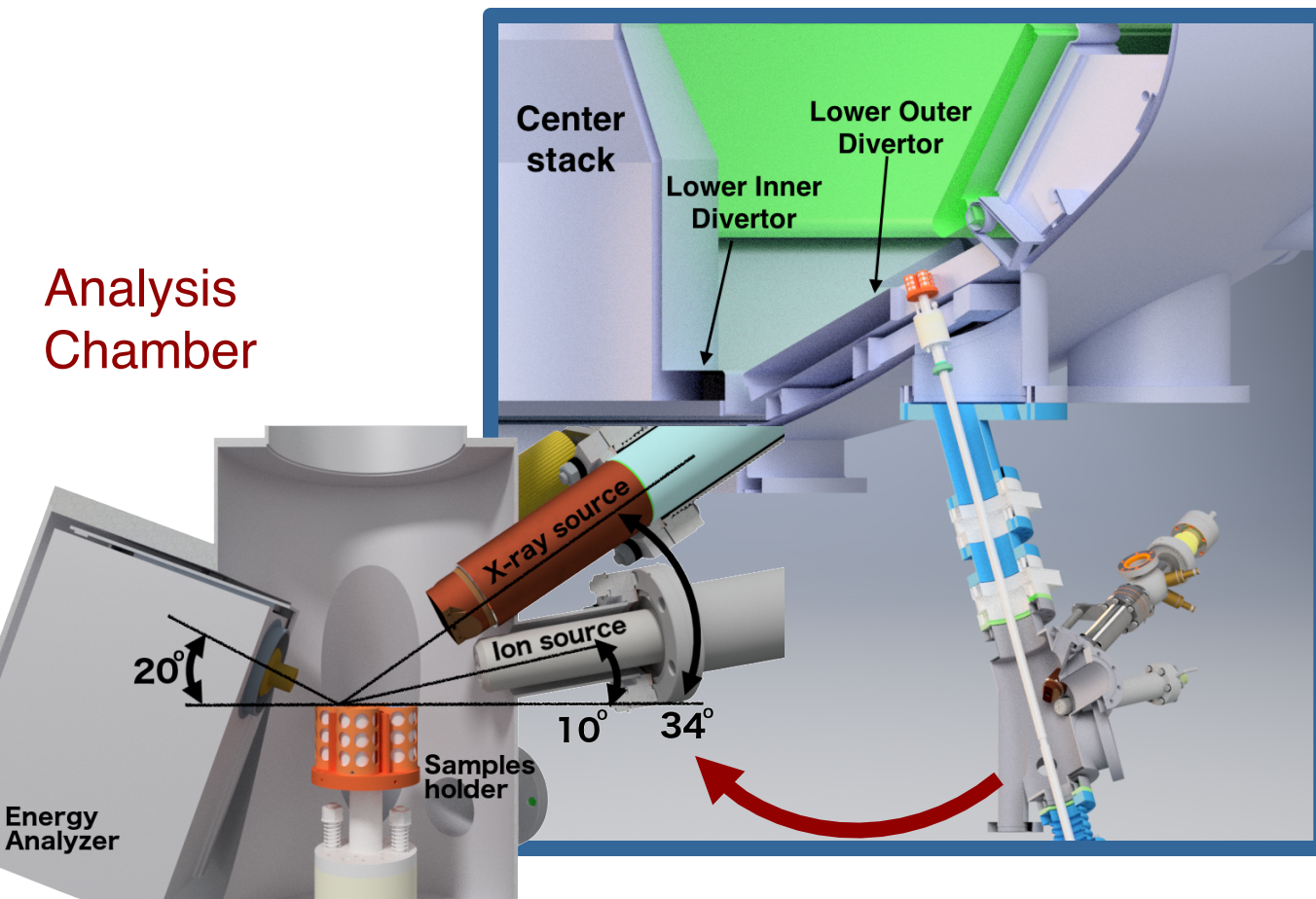




# Experimental methods

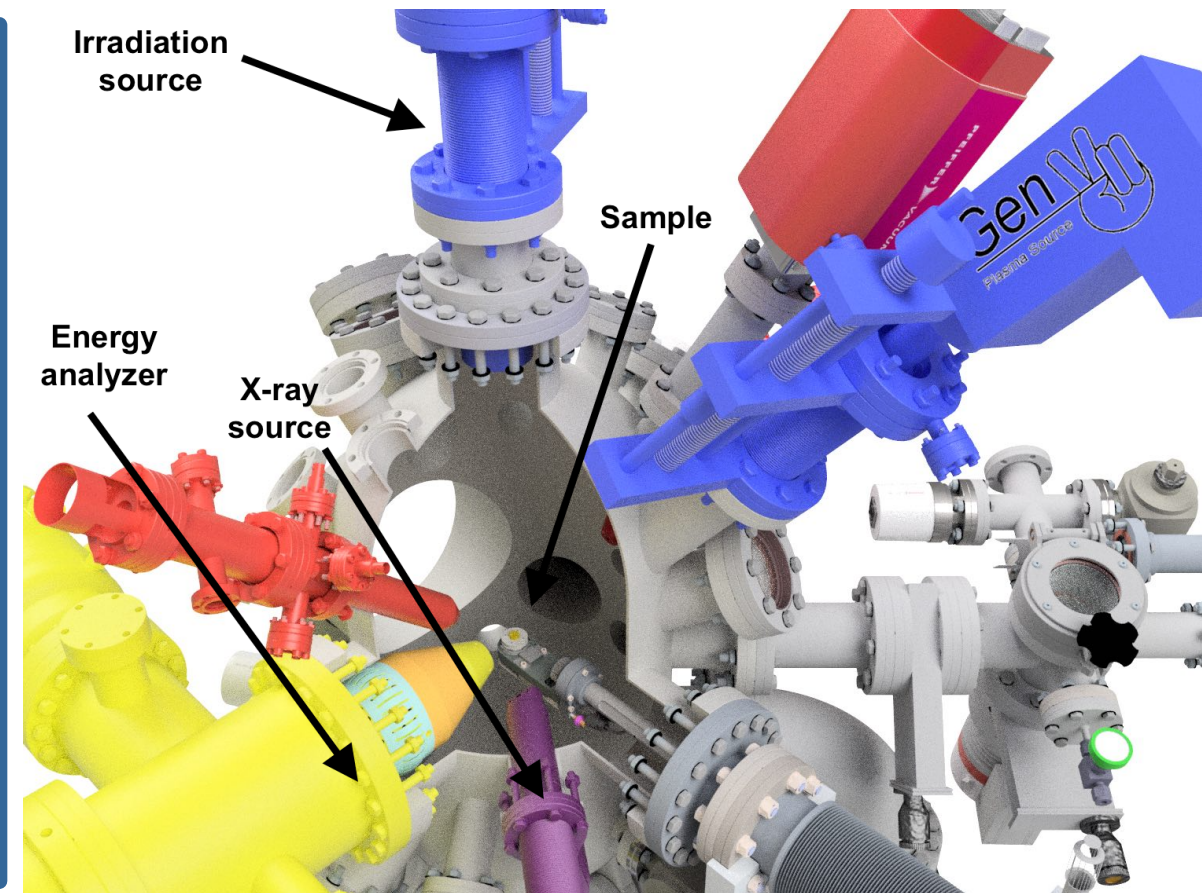
## Materials analysis in NSTX-U

### MAPP Facility



## Post-mortem and Controlled experiments at University of Illinois

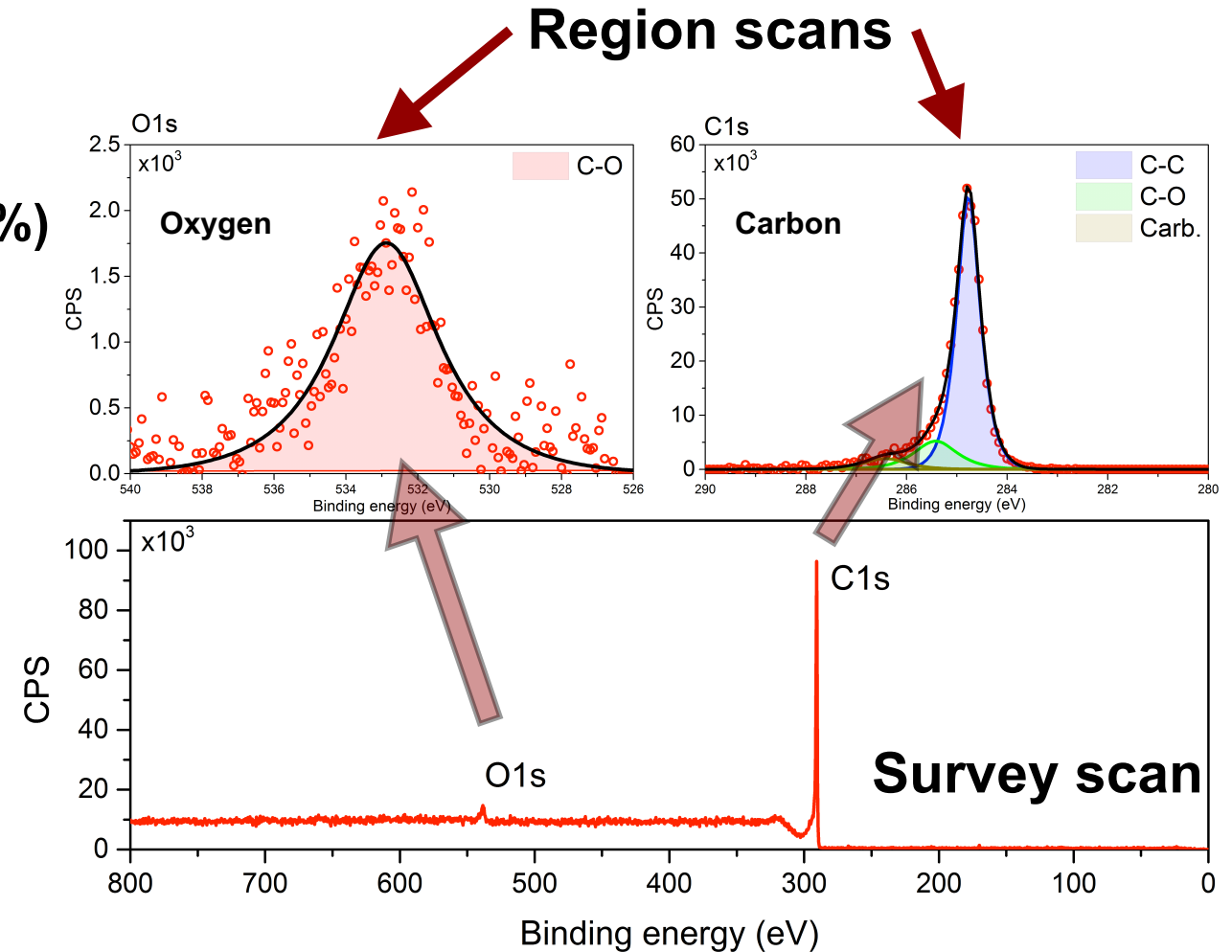
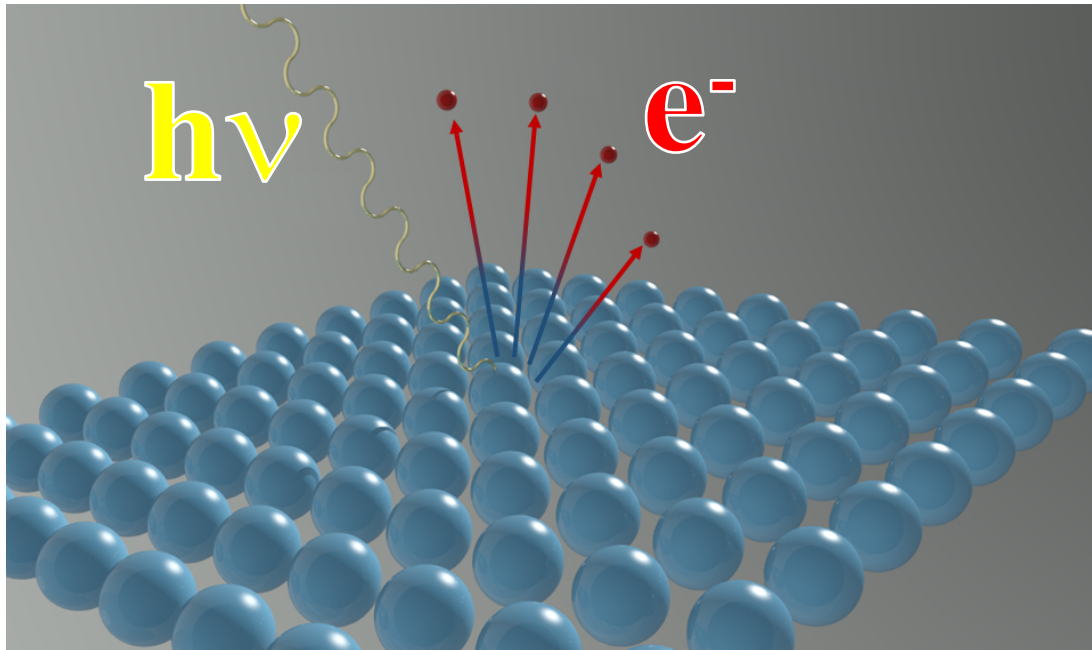
### IGNIS Facility





# Chemical identification of components via XPS

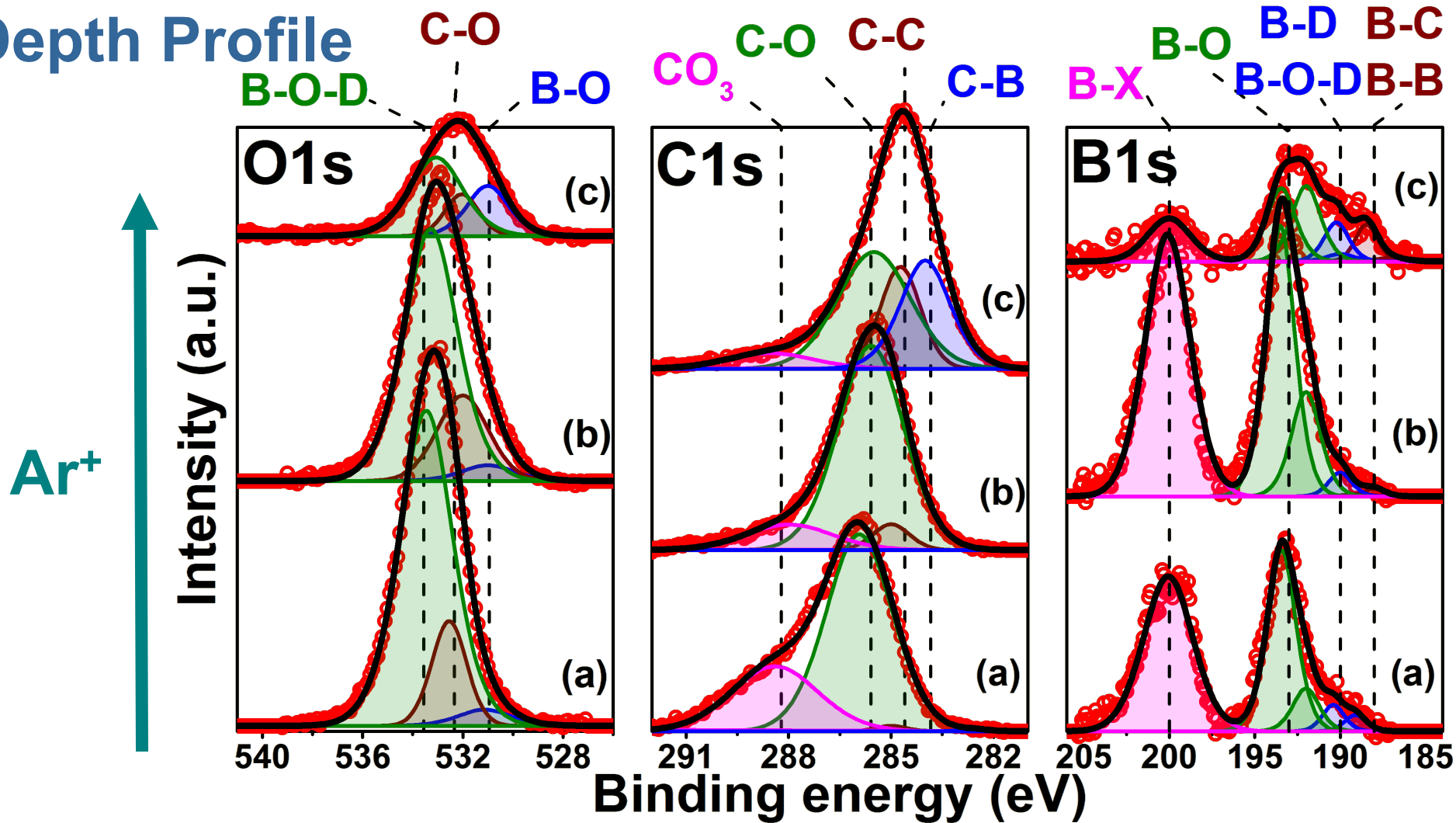
- Emission of photoelectrons under incident soft X-ray beam
- Probe top 10 – 20 nm of sample
- Elemental identification in survey scans
- Region scans allow quantitative analysis (at.%)



# Results

## Core B17 – XPS Depth Profile

- High presence of oxides throughout the whole experiment
- **Presence of a new XPS peaks, not previously observed, nor found in literature**
- Metallic states observable following Ar<sup>+</sup> irradiation



XPS peaks deconvolution of the depth profile data from core C18, (a) As is, (b)  $1 \times 10^{15}$  cgs Ar<sup>+</sup>, (c)  $3.5 \times 10^{17}$  cgs Ar<sup>+</sup>

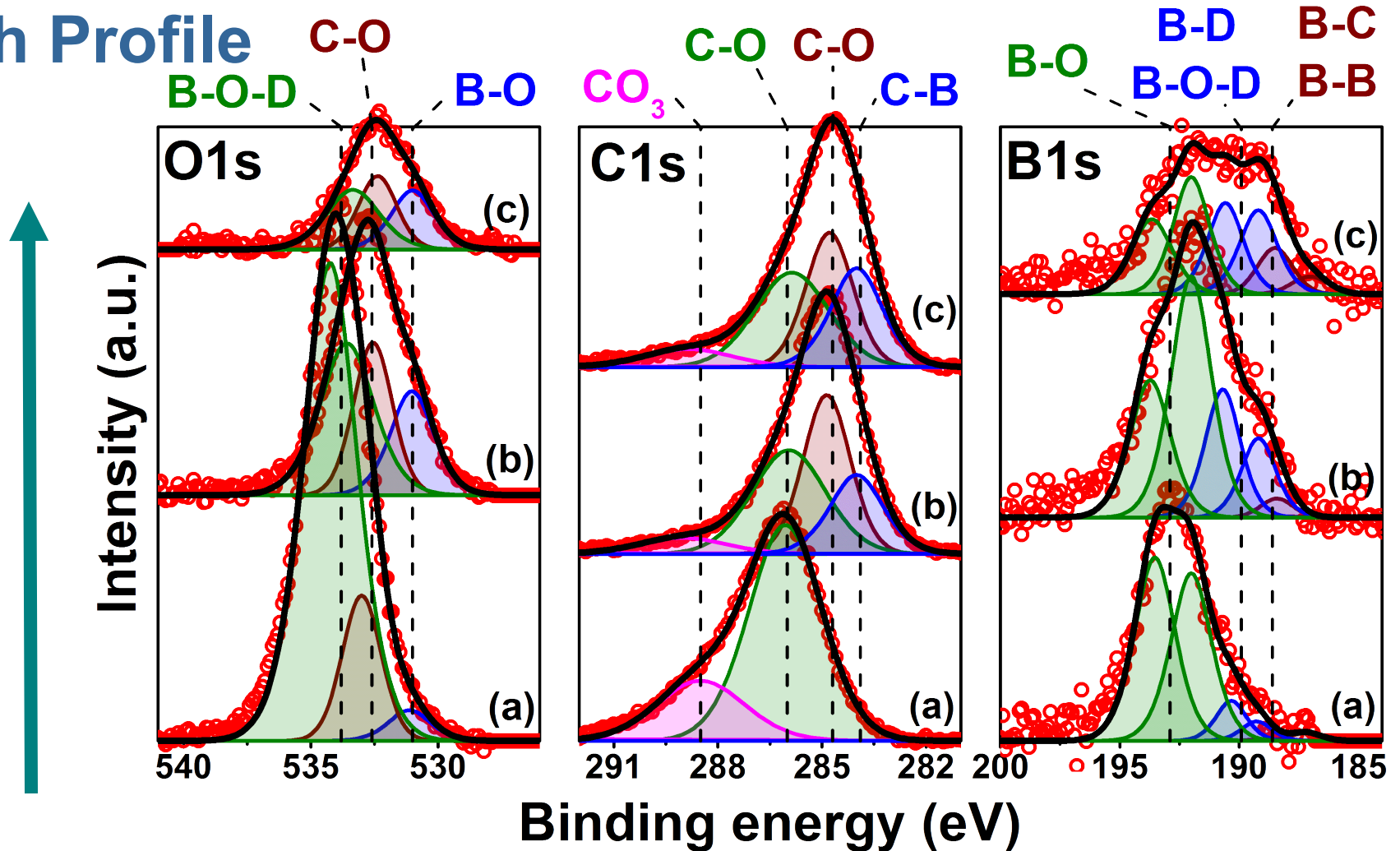


# Results

## Core A17 – XPS Depth Profile

- Initial high presence of oxides (lower concentration than other cores)
- Metallic states visible after Ar+
- **Post-cleaning state has the closes resemblance to post-boronized state from MAPP**

Ar<sup>+</sup>



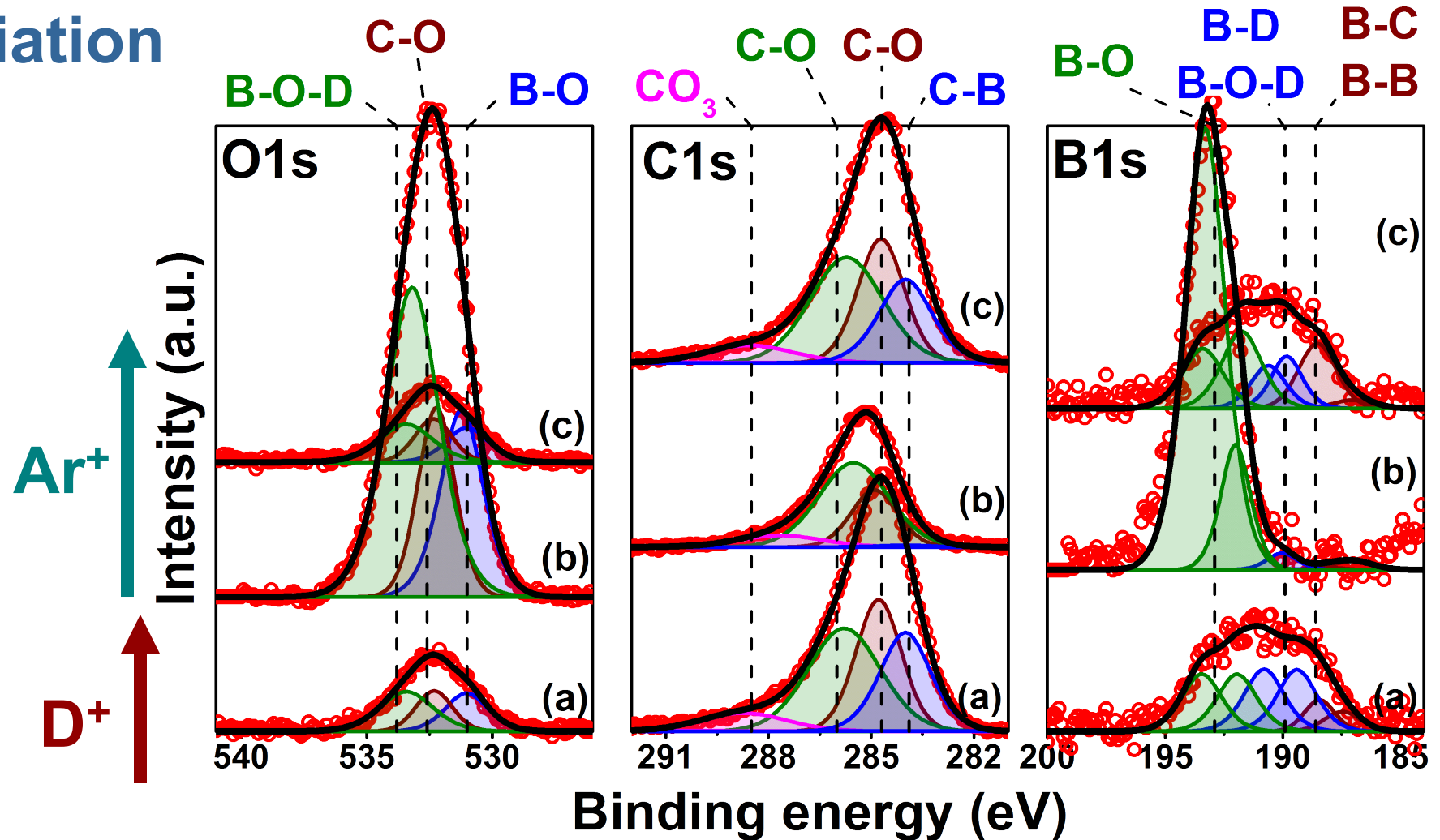
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# Results

## Core A17 – D<sup>+</sup> Irradiation

Deuterium irradiation drives oxidation of the B coatings, the oxides can be *easily* removed with additional irradiation.

Similar to what we observed in NSTX-U with MAPP !!



XPS peak deconvolution, (a)  $3.5 \times 10^{17}$  cm<sup>2</sup> Ar<sup>+</sup>, (b)  $6.0 \times 10^{16}$  cm<sup>2</sup> D<sup>+</sup> (c)  $2.0 \times 10^{17}$  cm<sup>2</sup> Ar<sup>+</sup>



# Conclusions

- Samples manufactured from tiles extracted from NSTX-U were characterized *post-mortem* using XPS and ion beam etching
- The boron concentrations on the three samples were different, implying possible non-uniform deposition during boronization
- The sample from the ILD, located at the PFR showed a second high energy XPS peak not previously observed. We hypothesize that this can be related to high D<sub>2</sub> presences or interactions with high  $E$  ions
- **D<sup>+</sup> irradiation of clean *post-mortem* sample showed similar behavior to that observed in MAPP:**
  - Deuterium ions driven oxidation
  - Plasma (Ar<sup>+</sup>) induced sputtering and oxides removal